

**University of Missouri-**



## 1. Objectives of the visit

*Chemical vapor deposition of perovskite thin films for functional devices*

## 2. Milestones Achieved

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Fig. 1:



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*Hybrid perovskite thin  
films by sequential low-pressure vapor deposition in a single reactor*

### 3. Value of the UM / UWC Exchange Program

### 4. Challenges and Suggestions

## 5. Acknowledgements